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Comparative characterization of Cu–Ni substrates for coated conductors

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Abstract

Three Cu₁₀₀−ₓNiₓ alloys, with x = 23, 33 and 45 at.%Ni, have been evaluated for use as substrates for coated conductors on the basis of measurements of their microstructure, crystallographic texture and hardness. It is found that high-temperature annealing after heavy rolling generates strong cube textures in each investigated alloy. For all of these alloys an increase in the annealing temperature from 800 °C to 1000 °C strengthens the cube texture and reduces the fraction of high angle grain boundaries. In the Cu–23 at.%Ni and Cu–33 at.%Ni alloys annealed at 1000 °C for 1 h, the fraction of the cube texture approaches 100% and the fraction of high angle boundaries is less than 4%. These two alloys are however very soft in the annealed condition. The cube texture in the Cu–45 at.%Ni substrate is slightly weaker than in the two other alloys, but this substrate

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is considerably harder, which makes it better suited for large scale production of superconducting tapes.

*Keywords: Cu–Ni alloys; RABiTS; Cube texture; EBSD*

1. Introduction

Cu–Ni alloys with low Curie temperatures [1–6] are considered to be possible alternatives to Ni–5at.%W and other Ni-based alloys [7–12] for use in the manufacture of YBa$_2$Cu$_3$O$_7$ coated conductors, as it is expected that the use of such Cu–Ni substrates, which are non-ferromagnetic at operating temperatures, will reduce energy losses in alternating current applications. Furthermore, since copper is significantly cheaper than nickel, the use of Cu–Ni substrates in coated conductors may also reduce cost.

To enable high critical current densities in a superconducting layer, the frequency of high angle boundaries (HABs) in the substrate should be small, which can be achieved via a so-called rolling assisted biaxially textured substrates (RABiTS) process [7,13], utilizing heavy rolling and high temperature annealing. In face centered cubic (fcc) materials, recrystallization after heavy rolling typically results in a strong \{001\}⟨100⟩ cube texture which further strengthens during grain growth. Since growing grains of similar \{001\}⟨100⟩ orientations frequently form low angle boundaries (LABs), the process of grain growth in the presence of a strong cube texture can effectively reduce the fraction of HABs in the final microstructure [5,14].

In several publications [1–6], it has been shown that a very strong cube texture can be obtained in Cu–Ni substrates, however the influence of the chemical composition
on the microstructure evolution during processing of such substrates has not been evaluated in these previous investigations. To enable a systematic comparative study, the evolution of microstructural parameters and texture in three different Cu–Ni substrates is thoroughly characterized in the present work using the electron backscatter diffraction (EBSD) technique. The EBSD characterization of the annealed substrates is complemented by measurements of their hardness.

2. Experimental

Cu–23 at.%Ni, Cu–33 at.%Ni and Cu–45 at.%Ni alloys (in the following termed Cu–23Ni, Cu–33Ni and Cu–45Ni, respectively) were prepared in a high-frequency induction furnace using high-purity (99.95 wt.%) Cu and Ni. The ingots were heated to 1000 °C and hot deformed to produce bars, which were ~10 mm thick and 15 mm wide. The hot-deformed bars were cooled in air, followed by surface grinding. The bars were then cold rolled applying 5% reduction per pass to a final thickness of 70 µm. The total thickness reduction by cold rolling for each sample was ~99%. The cold-rolled samples were annealed in a sealed quartz tube with inlet and outlet channels to allow the use of flowing Ar–5%H₂ gas. In these annealing experiments, the quartz tube containing the specimens was inserted into a preheated furnace. The heating-up time to reach the target temperature (either 800 °C, 900 °C or 1000 °C) for the specimens was measured to be 8–12 min. Following the heating-up period, most specimens were held in the furnace for 1 h. The actual temperature during this 1 h exposure could slightly deviate from the target temperature. For example, for a target temperature of 800 °C, the temperature steadily increased to 814 °C over the 1 h anneal duration, as measured using a thermocouple.
Such deviations are considered to be minor, and the target temperature is therefore given as the annealing temperature in the present work. In addition, a series of samples was prepared by heating up to 800 °C and annealing for different periods of time.

After annealing the quartz tube was retracted from the furnace, with the gas still flowing inside the tube, and tilted to allow the specimen to slide into a cold zone of the tube. This enabled quick cooling of the specimen inside the tube. According to our measurements, the specimen temperature dropped to below 100 °C within only 1 min.

Microstructures and textures of the samples were examined in a Zeiss Supra 35 field emission gun scanning electron microscope equipped with a Channel 5 EBSD system. A step size of 20 nm was used for collecting EBSD data in the cold-rolled samples. For partially recrystallized conditions, the EBSD step size was chosen to be either 100 nm or 200 nm. To measure microstructural parameters in the recrystallized samples, step sizes of 1 μm to 2.5 μm were applied for collecting EBSD maps from areas of at least 500 × 500 μm². Texture in the recrystallized samples was measured from areas of ~2 mm² investigated with a step size of 4 μm. LABs and HABs were defined as boundaries with misorientations of 2 − 15° and > 15°, respectively. In addition, the frequency of misorientations > 10° was also calculated for the annealed substrates because grain boundaries with such misorientations can significantly decrease the critical current density of an epitaxially grown YBa₂Cu₃O₇ layer [15]. All values representing the average grain size and boundary spacings along either the normal direction (d_{ND}), the transverse direction (d_{TD}), or the rolling direction (d_{RD}) were calculated in this work considering annealing twins to be grains. Following previous work on copper [16,17], Σ3 boundaries were defined by applying a maximum deviation of 3° from the ideal 60° <111> misorientation. Vickers hardness measurements were performed using a load
of 200 g with a dwell time of 15 s, averaging over at least 9 individual measurements for each condition.

3. Results

3.1 Samples after deformation

As shown in Fig.1, the samples obtained by hot deformation are fully recrystallized with a large frequency of annealing twins. The average grain size $D$ calculated from the Figure 1 for all crystallites including the twins is 16 µm, 12 µm and 9 µm for samples Cu–23Ni, Cu–33Ni and Cu–45Ni, respectively (see Table 1). The fraction of HABs ($f_{HAB}$) in these samples is similar, 97–98% (see Table 1). Furthermore, the hot-deformed samples are characterized by very weak crystallographic textures.

Heavy cold rolling results in strong rolling textures [5] and in a characteristic deformed microstructure comprising lamellar boundaries [18,19] almost parallel to the rolling plane and shear bands aligned at 22–36° to the RD (Fig.2). In each sample, $f_{HAB}$ is ~70%, whereas $d_{ND}$ varies from 77 nm for Cu–23Ni to 67 nm for Cu–45Ni (see Table 1).

3.2 Annealed samples

EBSD maps from the samples annealed at different temperatures for 1 h are shown in Fig.3, where it is seen that the area fraction of cube-oriented grains is sensitive both to the alloy composition and to the annealing temperature. Whereas there are significant frequencies of orientations with large deviations from the ideal cube orientation in the samples annealed at 800 °C, such grains are very rare after annealing at 1000 °C (see Fig.3). In the Cu–23Ni and Cu–33Ni samples, the fraction of orientations
within 10° of the ideal cube orientation \( f_{\text{Cube}} \) increases from 95–96% after annealing at 800 °C to almost 100% after annealing at 1000 °C (Fig.4). The cube texture is weaker in the Cu–45Ni sample, where \( f_{\text{Cube}} \) is 73% and 92% after annealing at 800 °C and 900 °C, respectively. However, after annealing at 1000°C the fraction of the cube texture becomes very high, \( f_{\text{Cube}} = 97\% \), even in this Ni-rich material (see Fig.4).

For the majority of the annealing conditions, the HAB fraction decreases both with decreasing Ni content and with increasing annealing temperature (see Table 1). The lowest fraction of HABs (less than 1%) is obtained in the Cu–23Ni sample annealed at 1000 °C for 1 h (see Fig.3). The fraction of boundary misorientations greater than 10° after annealing at this temperature is 21% in the Cu–45Ni sample and only 2–5% in the other samples (Fig.5).

The mean boundary spacing calculated as \( d_m = (d_{\text{TD}} + d_{\text{RD}})/2 \) generally decreases with increasing Ni content, though the difference in \( d_m \) between the Cu–33Ni and Cu–45Ni samples annealed at 800 °C and 900 °C is not significant (see Fig.6). For each alloy, an increase in the annealing temperature results in a coarser average grain size (Fig.6), which reduces the hardness (see Fig.7). The Vickers hardness measured after annealing at 1000 °C for 1 h is only 56 HV in the Cu–23Ni sample, but increases with increasing Ni content, reaching 77 HV in the Cu–45Ni sample (Fig.7).

4. Discussion

The three Cu–Ni alloys investigated in the present work are characterized by significant differences in the microstructure already in the hot-deformed condition (Fig.1 and Table 1). Since no deformation structure is observed in these hot-deformed samples, it is apparent that the temperature of the bars immediately after deformation was
sufficiently high to result in complete static recrystallization. The fact that the average recrystallized grain size in the hot-deformed Cu–23Ni sample was larger than the grain size in the two other samples suggests that in Cu–23Ni there were fewer recrystallization nuclei compared to the samples with the higher amounts of Ni.

Similar to the difference in the grain size after hot deformation (Fig.2), the largest spacing between lamellar boundaries is obtained for the Cu–23Ni sample, whilst the smallest spacing is recorded for the Cu–45Ni sample (see Table 1). In our previous study of Cu–45Ni [5], it has been shown that annealing after heavy rolling first leads to recovery, which involves a coarsening of the lamellar microstructure [20,21]. This initial stage is followed by discontinuous recrystallization and, finally, by grain growth. To identify each of these stages in the samples studied in the present work, hardness measurements were performed after different periods of time in the furnace preheated to enable annealing at ~800 °C. The results of these measurements are shown in Fig.8. It is seen that after only 1 minute, when the actual temperature reaches ~550 °C, the hardness decreases by approximately 10–20%. This initial softening is considered to be due to recovery leading both to reduced dislocation density and to lamellar coarsening. Further annealing up to 5 minutes, where the temperature is still below 800 °C (see Fig.8), leads to a pronounced drop in hardness, indicating discontinuous recrystallization. It is therefore clear that recrystallization in each alloy occurs during the heating-up period. Annealing beyond 5 minutes results in a slow reduction in hardness, which suggests that at this stage the microstructure evolves predominantly by growth of recrystallized grains. Comparing the three curves in Fig.8, it is apparent that the Cu–23Ni sample softens more rapidly than the other samples.
To observe the microstructure in partially recrystallized conditions, we investigated the Cu–23Ni and Cu–45Ni samples after 2 min in the furnace. As is evident from EBSD maps in Fig.9, there is a very large difference in the extent of recrystallization in these two samples. In the Cu–23Ni sample, recrystallized grains are fairly large (see Fig.9(a)), with an equivalent circular diameter (ECD) of up to \(40\text{–}60\ \mu\text{m}\), and the area fraction of the recrystallized microstructure is approximately 65%. In contrast, only a few small recrystallized grains (ECD < 5 \(\mu\text{m}\)) are observed in the Cu–45Ni sample, in which the lamellar microstructure is largely preserved (Fig.9(b)). It is therefore obvious that recrystallization in the low-Ni sample proceeds faster and results in larger grains than in the samples with the higher amounts of Ni. In general, these differences can be both due to the differences in the deformed microstructure of the alloys and due to differences in the solute drag [22,23]. As the latter controls the boundary migration, the large differences in the chemical composition could affect either or both of the processes involving boundary migration before and during recrystallization, namely initial coarsening of the lamellar structures, and nucleation and growth of recrystallization nuclei.

Analysis of orientations in the partially recrystallized Cu–23Ni sample indicates that the largest grains have orientations deviated by less than 10° from the ideal \(\{001\}\langle100\rangle\) orientation (see Fig.9(a)). The larger average size of cube-oriented grains as compared to grains of other orientations is in agreement with previous observations in other fcc materials [5,24,25]. Such large \(\{001\}\langle100\rangle\) grains gain growth advantage during further annealing, consuming grains of other orientations. During grain growth cube-oriented grains encounter one another, which leads to the formation of new LABs and reduces the fraction of boundaries with large misorientations (including those >10°, see
Fig. 5). The comparatively low fraction of the cube texture in the Cu−45Ni sample annealed at 800 °C (Fig. 4) suggests that for this alloy the boundary mobility at 800 °C was not high enough to effectively eliminate non-cube crystallites present in the microstructure. However, when the temperature increases to 900 °C and 1000 °C (which increases the boundary mobility), cube-oriented grains are able to grow very rapidly even in this Ni-rich alloy, and the difference in the fraction of the cube texture between the different alloys becomes smaller.

Considering that the fraction of boundaries with misorientations >10° is lowest in the Cu−23Ni sample annealed at 1000 °C for 1 h, it can be concluded that its microstructure is better suited in ensuring a high critical current density than the microstructure of the other two alloys. This alloy is, however, rather soft (see Fig. 7), which can cause handling issues during manufacturing of long coated conductor tapes. Taking into account that the hardness of the Cu−45Ni sample is higher than that of both Cu−23Ni and Cu−33Ni, and that its microstructural characteristics after annealing at 1000 °C for 1 h are sufficiently good even in comparison with the commonly used Ni−5 at.%W substrates [8], the Cu−45 at.%Ni alloy is considered to be a better candidate for potential use as a substrate material for coated conductors than the other two Cu−Ni alloys studied in the present work.

Summary

The evolution of the microstructure and crystallographic texture during deformation and annealing of Cu−23 at.%Ni, Cu−33 at.%Ni and Cu−45 at.%Ni alloys has been investigated in this work aiming at developing non-ferromagnetic substrates for coated conductors. After each processing step the boundary spacing is found to be consistently
greater in the alloy with the lowest Ni content. For each material, the cube texture strengthens and the frequency of boundaries with large misorientations decreases with increasing annealing temperature. After annealing at 1000 °C for 1 h the fraction of the cube texture in the Cu−23 at.%Ni alloy is almost 100% and the fraction of boundary misorientations >10° is only 2%. Although this microstructure is better suited in ensuring a high critical current density than the annealed microstructure of the other samples, the Cu–23 at.%Ni alloy annealed at 1000 °C is very soft, and therefore is not considered to be a good substrate material. In contrast, Cu–45 at.%Ni is characterized by the highest hardness, combined with sufficiently good microstructure and texture after annealing at 1000 °C for 1 h. Thus, the Cu–45 at.%Ni alloy annealed at 1000 °C for 1 h appears to be more suitable as a substrate material for coated conductors than the two other Cu–Ni alloys.

Acknowledgements

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References


Table 1 Microstructural parameters determined using the EBSD technique.

<table>
<thead>
<tr>
<th>Sample</th>
<th>Hot-deformed</th>
<th>Cold-rolled</th>
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<th>900 °C for 1 h</th>
<th>1000 °C for 1 h</th>
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</thead>
<tbody>
<tr>
<td></td>
<td>$D$ (µm) $f_{HAB}$ (%) $d_{ND}$ (nm) $f_{HAB}$ (%) $d_m$ (µm) $f_{HAB}$ (%) $d_m$ (µm) $f_{HAB}$ (%) $d_m$ (µm) $f_{HAB}$ (%)</td>
<td></td>
<td></td>
<td></td>
<td></td>
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<tr>
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<td>77</td>
<td>70</td>
<td>27</td>
</tr>
<tr>
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<td>75</td>
<td>71</td>
<td>17</td>
</tr>
<tr>
<td>Cu−45Ni</td>
<td>9</td>
<td>97</td>
<td>67</td>
<td>71</td>
<td>16</td>
</tr>
</tbody>
</table>
Fig. 1. EBSD maps showing the microstructure in the hot-deformed samples: (a) Cu–23Ni; (b) Cu–33Ni, (c) Cu–45Ni. LABs and HABs (other than $\Sigma 3$) are shown in gray and black, respectively. $\Sigma 3$ boundaries are shown in red. (For interpretation of the references to color, the reader is referred to the web version of this article.)
Fig. 2. EBSD maps showing the microstructure in the longitudinal section of the cold-rolled samples: (a) Cu–23Ni; (b) Cu–33Ni, (c) Cu–45Ni. LABs and HABs (other than Σ3) are shown in gray and black, respectively. Σ3 boundaries are shown in red. (For interpretation of the references to color, the reader is referred to the web version of this article.)
Fig. 3. EBSD maps from the rolling plane showing microstructures after annealing at different temperatures for 1 h. The color code for different deviations from the exact \(\{001\}\langle100\rangle\) orientation, \(\Delta\theta_{\text{Cube}}\), is given in the legend. LABs and HABs (other than \(\Sigma3\)) are shown in gray and black, respectively. \(\Sigma3\) boundaries are shown in red. (For interpretation of the references to color, the reader is referred to the web version of this article.)
Fig. 4. Fractions of the cube texture within 10° from the ideal \{001\}\langle100\rangle orientation after annealing at different temperatures for 1 h.

Fig. 5. Fractions of boundary misorientations >10° after annealing at different temperatures for 1 h.

Fig. 6. The average grain size measured in the rolling plane after annealing at different temperatures for 1 h.
Fig. 7. Vickers hardness after annealing at different temperatures for 1 h. The error bars correspond to the standard deviation.

Fig. 8. The evolution of the Vickers hardness after different periods of time in the furnace (black lines) for a target temperature of 800 °C, and an actual thermal profile (grey line) determined near the specimen location. “CR” corresponds to the cold-rolled condition. The dashed lines mark a period of time (between 1 minute and 5 minutes), during which a pronounced drop in hardness is observed.
Fig. 9. EBSD maps from the longitudinal section of the samples after 2 min in the furnace (when the temperature reached 670 °C, see Fig. 8): (a) Cu–23Ni and (b) Cu–45Ni. The color code for different deviations from the exact \{001\}(100) orientation, $\Delta \theta_{\text{Cube}}$, is given in the legend. Black and thin gray lines show HABs (other than $\Sigma 3$) and LABs, respectively. $\Sigma 3$ boundaries are shown in red. The scale bar is parallel to the RD. (For interpretation of the references to color, the reader is referred to the web version of this article.)